Acta Crystallographica Section E

## Structure Reports Online

ISSN 1600-5368

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## Key indicators

Single-crystal X-ray study
$T=295 \mathrm{~K}$
Mean $\sigma(\mathrm{C}-\mathrm{C})=0.003 \AA$
$R$ factor $=0.040$
$w R$ factor $=0.133$
Data-to-parameter ratio $=11.7$
For details of how these key indicators were automatically derived from the article, see http://journals.iucr.org/e.

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## (E)-9,10-Dihydro-9-methyl-9-nitro-10(trinitromethyl)anthracene

The title compound, $\mathrm{C}_{16} \mathrm{H}_{12} \mathrm{~N}_{4} \mathrm{O}_{8}$, was prepared by the photochemical reaction of 9-methylanthracene and tetranitromethane in dichloromethane. Intermolecula face-to-face $\pi-\pi$ stacking interactions are present along the $a$ axis.

## Comment

Photonitration of various aromatic compounds using tetranitromethane (TNM) has attracted some attention as an alternative to the conventional nitration processes which require the use of concentrated nitric and sulfuric acids (Kochi, 1991; Butts et al., 1996; Cox, 1998; Lehnig \& Schürmann, 1998). There are two possible photonitration products depending on the nature of the aromatic compound. In general, unsubstituted non-heteroaromatic compounds result in nitration, while alkyl substituted ones, such as 9-methylanthracene, lead to the addition of both trinitromethyl and nitro groups. Owing to the dissociative fragmentation of TNM, irradiation of the 9-methylanthracen/TNM charge-transfer (CT) complex leads to the formation of a triad consisting of a 9-methylanthraceneradical cation, a nitrogen dioxide radical and a trinitromethide anion. The subsequent addition reactions occur at the C9 and C10 positions of the anthracene central ring. The larger trinitromethyl group adds first through an ion-pair collapse and reorders pseudoaxially at the C10 position of the central dihydroanthracene ring. In order to form a more stable hydranthryl radical, the trinitromethide addition to 9-methylanthracene occurs at the less hindered C10 site. Radical-radical coupling between nitrogen dioxide and the resulting hydranthryl radical takes place from the site opposite to the trinitromethyl group.

Received 26 October 2005 Accepted 10 November 2005 Online 16 November 2005

(I)

We report here the crystal structure of the title compound, (I), as the photoreaction product of 9-methylanthracene with TNM (Fig. 1). The bond lengths and angles of the tricyclic ring


Figure 1
ORTEP-3 (Farrugia, 1997) drawing of (I), with the atom-numbering scheme. Displacement ellipsoids for non-H atoms are drawn at the $40 \%$ probability level.
system are in agreement with those of alkyl-substituted 9,10dihydroanthracenes (Brinkmann et al., 1970; Rabideau, 1978; Dalling et al., 1981). The larger trinitromethyl group is attached pseudoaxially at the C10 position of the meso ring, which adopts a boat conformation. Pseudoaxial positioning of the bulkier groups in other 9,10-dihydroanthracene derivatives is also known (Cam \& Bock, 1978; Dalling et al., 1981). The trinitromethyl and nitro groups prefer to have a trans configuration. The dihedral angle between the two benzene ring planes is $28.93(9)^{\circ}$. The bond distance between C9 and the methyl atom $\mathrm{C} 11[1.523$ (3) $\AA$ ] is shorter than that between C10 and the trinitromethyl atom C12 [1.582 (3) A] owing to the high functionalities of the nitro groups. The bond distance between C9 and N9 [1.563 (3) A] is $0.033 \AA$ longer than the average length of the other $\mathrm{C} 12-\mathrm{N}$ bonds. In addition to van der Waals forces, $\pi-\pi$ interactions between one benzene ring of two neighboring molecules contribute to the stacking along the $a$ axis (Fig. 2).

## Experimental

The title compound was synthesized by irradiation of a solution containing 9 -methylanthracene ( $100 \mathrm{mg}, 0.52 \mathrm{mmol}$ ) and tetranitromethane ( $325 \mathrm{mg}, 1.67 \mathrm{mmol}$ ) in pentane ( 49 ml ) and $\mathrm{CCl}_{4}(1 \mathrm{ml})$. A 500 nm cut-off filter was used to ensure that only the CT complex was excited, not the uncomplexed initial components present in the solution. The solution was purged with argon before and during the irradiation ( 30 min ). After the irradiation, the solvents were removed and (I) ( $55 \mathrm{mg}, 27.2 \%$ ) was isolated by fractional crystallization from dichloromethane as colorless prisms (m.p. 421-422 K). ${ }^{1} \mathrm{H}$ NMR ( $300 \mathrm{MHz}, \mathrm{CDCl}_{3}$, p.p.m.): $\delta 7.59-7.41(\mathrm{~m}, 8 \mathrm{H}), 6.405(s, 1 \mathrm{H}), 2.48(s$, 3H).


Figure 2
The molecular packing of (I), viewed down the $a$ axis. H atoms have been omitted for clarity.

## Crystal data

$\mathrm{C}_{16} \mathrm{H}_{12} \mathrm{~N}_{4} \mathrm{O}_{8}$
$M_{r}=388.3$
Monoclinic, $P 2_{1} / n$
$a=7.9797$ (6) A
$b=13.5449(10) \AA$
$c=15.3793$ (9) $\AA$
$\beta=91.816(6)^{\circ}$
$V=1661.4$ (2) $\AA^{3}$
$Z=4$

## Data collection

Enraf-Nonius CAD-4 diffractometer $\omega$ scans
Absorption correction: none 2949 measured reflections 2949 independent reflections 2311 reflections with $I>2 \sigma(I)$

## Refinement

Refinement on $F^{2}$
$R\left[F^{2}>2 \sigma\left(F^{2}\right)\right]=0.040$
$w R\left(F^{2}\right)=0.133$
$S=1.06$
2949 reflections
253 parameters
H -atom parameters constrained

$$
D_{x}=1.552 \mathrm{Mg} \mathrm{~m}^{-3}
$$

Mo $K \alpha$ radiation
Cell parameters from 25 reflections
$\theta=20-25^{\circ}$
$\mu=0.13 \mathrm{~mm}^{-1}$
$T=295$ (2) K
Prism, colorless
$0.35 \times 0.35 \times 0.18 \mathrm{~mm}$

$$
\theta_{\max }=25.1^{\circ}
$$

$h=-9 \rightarrow 9$
$k=0 \rightarrow 16$
$l=0 \rightarrow 18$
3 standard reflections frequency: 120 min intensity decay: $1.1 \%$

$$
\begin{aligned}
& w=1 /\left[\sigma^{2}\left(F_{\mathrm{o}}^{2}\right)+(0.1197 P)^{2}\right. \\
& \quad+9.7917 P] \\
& \text { where } P=\left(F_{\mathrm{o}}{ }^{2}+2 F_{\mathrm{c}}^{2}\right) / 3 \\
& (\Delta / \sigma)_{\max }=0.015 \\
& \Delta \rho_{\max }=0.21 \mathrm{e} \AA^{-3} \\
& \Delta \rho_{\min }=-0.15 \mathrm{e}^{-3}
\end{aligned}
$$

Table 1
Selected geometric parameters $\left(\AA^{\circ},{ }^{\circ}\right)$.

| $\mathrm{N} 3-\mathrm{C} 12$ | $1.526(3)$ | $\mathrm{N} 2-\mathrm{C} 12$ | $1.540(3)$ |
| :--- | ---: | :--- | :--- |
| $\mathrm{N} 1-\mathrm{C} 12$ | $1.531(3)$ | $\mathrm{C} 10-\mathrm{C} 12$ | $1.582(3)$ |
| $\mathrm{N} 9-\mathrm{C} 9$ | $1.563(3)$ | $\mathrm{C} 9-\mathrm{C} 11$ | $1.523(3)$ |
|  |  |  |  |
| $\mathrm{C} 10 a-\mathrm{C} 10-\mathrm{C} 4 a$ | $112.93(17)$ | $\mathrm{C} 9 a-\mathrm{C} 9-\mathrm{C} 8 a$ | $112.98(18)$ |
| $\mathrm{C} 9 a-\mathrm{C} 9-\mathrm{C} 11$ | $113.44(19)$ | $\mathrm{C} 11-\mathrm{C} 9-\mathrm{C} 8 a$ | $112.5(2)$ |

H atoms were positioned geometrically and allowed to ride on their parent atoms with $\mathrm{C}-\mathrm{H}=0.93,0.96$ and $0.98 \AA$ for aromatic, methyl and methine H atoms, respectively, with $U_{\text {iso }}(\mathrm{H})=1.5 U_{\text {eq }}(\mathrm{C})$ of the parent atom for the methyl groups and $1.2 U_{\text {eq }}(\mathrm{C})$ for the rest.

Data collection: CAD-4-PC Software (Enraf-Nonius, 1993); cell refinement: CAD-4-PC Software; data reduction: DATRD2 in NRCVAX (Gabe et al., 1989); program(s) used to solve structure: SHELXS97 (Sheldrick, 1997); program(s) used to refine structure: SHELXL97 (Sheldrick, 1997); molecular graphics: ORTEP-3 for Windows (Farrugia, 1997) and PLATON/PLUTON (Spek, 2003);
software used to prepare material for publication: WinGX (Farrugia, 1999).

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